

Notice of References Cited	Application/Control No. 10/044,842		Applicant(s)/Patent Under Reexamination RAAD ET AL.	
	Examiner Brad Y. Chin		Art Unit 1744	Page 1 of 1

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*	U	Kirk-Othmer Encyclopedia of Chemical Technology, 3rd Edition, Volume 5, pp. 857-884.
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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
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